

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Jeong-hee Chung et al.

Serial No: To Be Assigned

Filed: Concurrently Herewith

For: SEMICONDUCTOR CAPACITORS HAVING TANTALUM OXIDE LAYERS  
AND METHODS FOR MANUFACTURING THE SAME

Continuation of Serial No.: 10/047,706

Filed: January 15, 2002

Date: March 24, 2004

Mail Stop PATENT APPLICATION

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

**INFORMATION DISCLOSURE STATEMENT**

Sir:

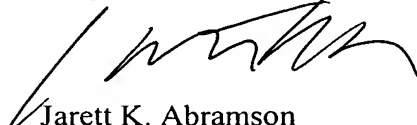
Attached is a copy of three form(s) PTO-1449 as filed in parent application serial number 10/047,706, with the application serial number and filing date of the parent application struck through.

A copy of each of the references above has been submitted to, or cited by, the Examiner in the parent application and is not provided herewith.

It is requested that all of these documents be considered by the Examiner and officially made of record in accordance with the provisions of 37 C.F.R. §1.56 and Section 609 of the MPEP.

No fee is believed due. However, the Commissioner is hereby authorized to charge any deficiency or credit any overpayment to Deposit Account No. 50-0220.

Respectfully submitted,



Jarett K. Abramson

Registration No. 47,376

**Customer No. 20792**

Myers Bigel Sibley & Sajovec

P. O. Box 37428

Raleigh, North Carolina 27627

Telephone: (919) 854-1400

Facsimile: (919) 854-1401

**CERTIFICATE OF EXPRESS MAILING**

"Express Mail" mailing label number: EV 193584260 US

Date of Deposit: March 24, 2004

I hereby certify that this paper or fee is being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated above and is addressed to Mail Stop PATENT APPLICATION, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.



Clara R. Beard







**Serial No.**  
**To be**  
**assigned**

(Use several sheets if necessary)

**Filing Date: Concurrently herewith**

**Group: Not yet known**

[illegible]

		Document Number	Date	Country	Class	Subclass	Translation Yes   No


DATE CONSIDERED

Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



Substitute form 1449A/PTO				<b>Complete if Known</b>	
<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (use as many sheets as necessary)				Application Number	<del>40/017,760</del>
				Filing Date	01/15/2002
				First Named Inventor	Jeong-hee Chung
				Group Art Unit	2814
				Examiner Name	
Sheet	1	of	1	Attorney Docket Number	5649-919 DV

U.S. PATENT DOCUMENTS						
Examiner Initials*	Cite No.	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code (if known)			

FOREIGN PATENT DOCUMENTS								
Examiner Initials*	Cite No.	Foreign Patent Document			Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T
		Office	Number	Kind Code (if known)				
	1	KR	1996-035876		Samsung Electronics Co., Ltd.	10/28/1996		X
	2	KR	1998-026863		Samsung Electronics Co., Ltd.	07/15/1998		X

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS			
Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T
	3	Notice to Submit Response, KR Application No. 10-2001-0003165, August 22, 2002	X

Examiner Signature		Date Considered	
--------------------	--	-----------------	--

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.